

RCE 1/10/07

PATENT  
Atty. Dkt. No. APPM/005191.C1(Y1)ISM/CORE MCVD/PJS

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:  
Lawrence C. Lei

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Serial No.: 10/792,323

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Confirmation No.: 4370

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Filed: March 3, 2004

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For: Apparatus and Method for  
Vaporizing Solid Precursor  
for CVD or Atomic Layer  
Deposition

Group Art Unit: 3742

Examiner: Sang Y. Paik

**MAIL STOP AF**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

**RESPONSE TO FINAL OFFICE ACTION DATED OCTOBER 13, 2006**

In response to the Final Office Action dated October 13, 2006, having a shortened statutory period for response set to expire on January 13, 2007, please enter this response and reconsider the claims pending in the application for reasons discussed below. Although Applicant believes that no additional fees are due in connection with this response, the Commissioner is hereby authorized to charge counsel's Deposit Account No. 20-0782/APPM/005191.C1(Y1)/KMT, for any fees, including extension of time fees or excess claim fees, required to make this response timely and acceptable to the Office.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper. Remarks begin on page 5 of this paper.